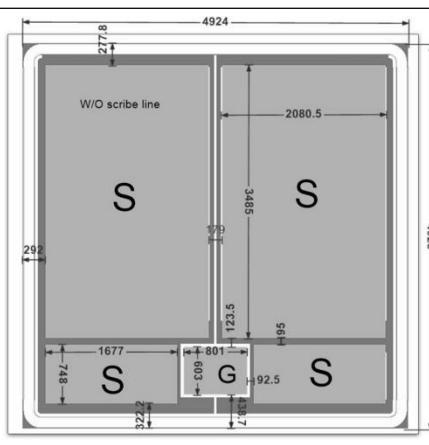
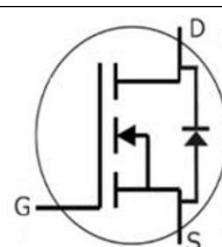


Physical Characteristics

	<p>Die size: 4924 μm x 4928 μm (without scribe line) Gate pad: 801 μm x 603 μm Gross die / per 6" wafer = 588 pcs</p> <p>Main characteristics: $V_{DS} = 750\text{V}$ $I_D(T_C=25^\circ\text{C}) = 189\text{A}$ $R_{DS(on)MAX} = 15\text{m}\Omega @ 18\text{V}$</p>
	

Mechanical Data

Parameter	Parameter
Nominal Back Metal Composition, Thickness	Ti-Ni-Ag
Nominal Front Metal Composition, Thickness	Al(4um)-Ni(2um)-Pd(0.2um)-Au(0.05um)
Wafer Diameter	150mm
Wafer Thickness	175 μm ±10 μm
Scribe line width	80 μm

Absolute Maximum Ratings ($T_C=25^\circ\text{C}$, unless otherwise specified)

Parameter	Symbol	Test Condition	Value	Unit
Drain-Source Voltage	V_{DS}	$V_{GS} = 0\text{V}$, $I_D = 100\mu\text{A}$	750	V
Gate-Source Voltage	V_{GSmax}	AC ($f > 1\text{ Hz}$)	-10/+25	V
Gate-Source Voltage	V_{GSOP}	Static	-4/+18	V
Continuous Drain Current	I_D	$V_{GS} = 18\text{V}$, $T_C=25^\circ\text{C}$	189	A
	I_D	$V_{GS} = 18\text{V}$, $T_C=100^\circ\text{C}$	133	
Pulsed Drain Current	$I_{D,pulse}$	Pulse with t_p limited by T_{jmax}	356	A
Junction Temperature	T_J		-55~ +175	°C
Storage Temperature	T_{STG}		-55~ +175	°C

Note 1: Assumes a $R_{th(jc)}$ will be less than 0.26 K/W.

Electrical characteristics ($T_j=25^\circ\text{C}$, unless otherwise noted)

Parameter	Symbol	Test Condition	Min.	Typ.	Max.	Unit
Static Characteristics						
Drain-source breakdown voltage	$V_{(\text{BR})\text{DSS}}$	$V_{\text{GS}} = 0\text{V}, I_D = 100\mu\text{A}$	750			V
Zero gate voltage drain current	I_{DSS}	$V_{\text{DS}} = 750\text{V}, V_{\text{GS}} = 0\text{V}$		1	50	μA
Gate-Source leakage current	I_{GSS}	$V_{\text{GS}} = 18\text{V}, V_{\text{DS}} = 0\text{V}$			250	nA
Gate threshold voltage	$V_{\text{GS}(\text{th})}$	$V_{\text{DS}} = V_{\text{GS}}, I_D = 36\text{mA}$ $V_{\text{DS}} = V_{\text{GS}}, I_D = 36\text{mA}, T_j = 175^\circ\text{C}$		2.8		V
Drain-source on-resistance	$R_{\text{DS}(\text{on})}$	$V_{\text{GS}} = 18\text{V}, I_D = 80\text{A}$ $V_{\text{GS}} = 18\text{V}, I_D = 80\text{A}, T_j = 175^\circ\text{C}$		11	15	$\text{m}\Omega$
Transconductance	g_{fs}	$V_{\text{DS}} = 18\text{V}, I_D = 80\text{A}$ $V_{\text{DS}} = 18\text{V}, I_D = 80\text{A}, T_j = 175^\circ\text{C}$		60		S
Dynamic characteristics						
Input Capacitance	C_{iss}	$V_{\text{DS}} = 600\text{V}, V_{\text{GS}} = 0\text{V}, f = 1\text{MHz}$ $V_{\text{AC}} = 25\text{mV}$		5670		pF
Output Capacitance	C_{oss}			383		
Reverse Transfer Capacitance	C_{rss}			37		
Total Gate Charge	Q_g	$V_{\text{DS}} = 400\text{V}, I_D = 80\text{A}$ $V_{\text{GS}} = -4\text{V}/18\text{V}$		235		nC
Gate-Source Charge	Q_{gs}			84		
Gate-Drain Charge	Q_{gd}			62		
Internal Gate Resistance	$R_{\text{G}(\text{int})}$	$f = 1 \text{ MHz}, V_{\text{AC}} = 25\text{mV}$		1.2		Ω
Source-Drain Diode characteristics						
Diode Forward Current	I_s	$V_{\text{GS}} = -4\text{V}, T_c = 25^\circ\text{C}$		130		A
Diode Forward voltage	V_{SD}	$V_{\text{GS}} = -4\text{V}, I_{\text{SD}} = 40\text{A}$		3.9		V
Diode Pulse Current	$I_{\text{S,pulse}}$	$V_{\text{GS}} = -4\text{V}, \text{pulse width } t_p \text{ limited by } T_{j\text{max}}$		3.4		V
				356		A

Note: The electrical characteristics are the test results of the chip using TO-247AB packaging.